ROCHESTER INSTITUTE OF TECHNOLOGY MICROELECTRONIC ENGINEERING

# **BJT Characterization Laboratory**

# **Dr. Lynn Fuller**

Microelectronic Engineering Rochester Institute of Technology 82 Lomb Memorial Drive Rochester, NY 14623-5604 Tel (585) 475-2035 Fax (585) 475-5041 Email: Lynn.Fuller@rit.edu Dr. Fuller's Webpage: http://people.rit.edu/lffeee MicroE Webpage: http://www.microe.rit.edu

Rochester Institute of Technology Microelectronic Engineering 2-12-2014 Lab\_BJT\_Characterization.ppt

© February 12, 2014 Dr. Lynn Fuller

### **OUTLINE**

2N3904 BE Junction BC Junction IC-VCE Family of Curves Beta at low, medium, high currents SPICE Models Temperature Effects

**Rochester Institute of Technology** 

Microelectronic Engineering

© February 12, 2014 Dr. Lynn Fuller

## **DEFINITIONS**

<u>Bipolar Junction Transistor</u> - (BJT) Both holes and electrons participate in the conduction of current, hence the name bipolar.

<u>Minority carrier</u> - In a p-type semiconductor electrons are the minority carrier type, in an n-type semiconductor holes are the minority carrier type.

<u>Emitter</u> - Emits minority carriers into the base region of a BJT. For example, in an NPN BJT the n-type emitter, emits electrons into the p-type base. The emitter usually has the highest doping levels of the three regions of a BJT.

<u>Base</u> - Thin region which is used to control the flow of minority carriers from the emitter to the collector

<u>Collector</u> -Collects the minority carriers that make it through the base from the emitter. The collector usually has the lightest doping concentrations of the three regions.

 $\frac{DC \ Beta}{AC \ Beta} (\beta_{dc}) \text{ - The ratio of the collector current to the base current. } \beta_{dc} = I_C \ / \ I_B \\ \frac{AC \ Beta}{AC \ Beta} (\beta_{ac}) \text{ - The ratio of the change in the collector current to the change in the base current. } \beta_{ac} = \Delta \ I_C \ / \ \Delta \ I_B$ 

### **BJT - BIPOLAR JUNCTION TRANSISTOR**



Rochester Institute of Technology

Microelectronic Engineering



The world's first transistor, built at Bell Labs in December, 1947.



Transistor inventors (from left), Dr. Walter Brattain, Dr. William Shockley, and Dr. John Bardeen.

© February 12, 2014 Dr. Lynn Fuller



## **SCHEMATIC SYMBOLS**







### **COMMENTS**

1. The concentration of electrons in n-type silicon is  $\sim$  doping concentration in that region.

2. In p-type silicon the number of electrons is almost zero

3. A forward biased pn junction means more carriers of both types can cross the potential barrier. So a forward biased base-emitter junction (in an npn BJT) means more electrons on the base side than in equilibrium (no bias).

4. A reverse biased pn junction means less carriers of both types can cross the potential barrier. So a reverse biased base-collector junction (in an npn BJT) means less electrons on the base side than in equilibrium (no bias). Even closer to zero electrons in p-type base at the edge of the B-C space charge layer.

5. The base is so narrow that few electrons are lost as they diffuse across the base width. Diffusion is driven by a concentration gradient. So electrons move towards the collector and current flows in the opposite direction.



#### HP4145B SEMICONDUCTOR PARAMETER ANALYZER SE SEMICONDUCTOR PLALMETER ANALYZER ANALYZER 2 王确之在177 中正公米正年已 SOFTKEVS PAGE CONTROL WELSUREWENT WENL DEPE LT 1 340FT MENT T PARTY LAUTO CAL ENTRY ENTER TO BOX FORMUL RO MEASURING C 8 9 LINE OFF ON D = INTENSITY 4 5 10 10 10 10.001 2 3 FOCUS USER FILE na 11 11 11 11 10 10 10 10 GET 0 8

© February 12, 2014 Dr. Lynn Fuller

## **TEST EQUIPMENT**



### **TEST STATION**



© February 12, 2014 Dr. Lynn Fuller

**OPERATION OF HP4145 AND SWITCH MATRIX** 

Turn on the HP4145, Switch Matrix, and PC Select ICS icon on the desktop (close and message window) Click on GPIB icon on the top of the screen select NI-32Thunk Click on Instrument icon and select HP4145 Click on device icon and select PN Diode or BJT Click on SMU1 then click on terminal (n-side of diode) set SMU1 to zero volts ground Click on SMU2 then click on terminal (p-side of diode) set SMU2 to sweep from -10 to 10 Volts, measure I and V Click on done Click on measure button

Wait for data to graph then add cursors, lines, titles, source conditions

### 2N3904 DATA SHEET



\*\* Device mounted on FR-4 PCB 36 mm X 18 mm X 1.5 mm; mounting pad for the collector lead min. 6 cm<sup>2</sup>

Symbol	Parameter	Test Conditions	Min	Max	Units
OFF CHAP	RACTERISTICS	_		_	_
V <sub>(BR)CEO</sub>	Collector-Emitter Breakdown Voltage	I <sub>C</sub> = 1.0 mA, I <sub>B</sub> = 0	40		V
V <sub>(BR)</sub> CBO	Collector-Base Breakdown Voltage	I <sub>c</sub> = 10 μA, I <sub>E</sub> = 0	60		V
V <sub>(BR)EBO</sub>	Emitter-Base Breakdown Voltage	I <sub>E</sub> = 10 μA, I <sub>C</sub> = 0	6.0		V
IBL	Base Cutoff Current	V <sub>CE</sub> = 30 V, V <sub>EB</sub> = 3V		50	nA
ICEX	Collector Cutoff Current	V <sub>CE</sub> = 30 V, V <sub>EB</sub> = 3V		50	nA
		$I_c = 50 \text{ mA}, V_{CE} = 1.0 \text{ V}$ $I_c = 50 \text{ mA}, V_{CE} = 1.0 \text{ V}$ $I_c = 100 \text{ mA}, V_{CE} = 1.0 \text{ V}$	60 30	300	
N CHAR	DC Current Gain	$I_c = 0.1 \text{ mA}, V_{ce} = 1.0 \text{ V}$	40		
Vorme	Collector-Emitter Saturation Voltage	I <sub>c</sub> = 50 mA, V <sub>cE</sub> = 1.0 V I <sub>c</sub> = 100 mA, V <sub>cE</sub> = 1.0 V I <sub>c</sub> = 10 mA, I <sub>c</sub> = 1.0 mA	60 30	0.2	v
· CE(SB()	Concercion Ennicer Contacturer Ventage	$I_{c} = 50 \text{ mA}, I_{B} = 5.0 \text{ mA}$		0.3	v
V <sub>BE(sat)</sub>	Base-Emitter Saturation Voltage	$l_c = 10 \text{ mA}, l_B = 1.0 \text{ mA}$	0.65	0.85	V
		$I_{C} = 50 \text{ mA}, I_{B} = 5.0 \text{ mA}$		0.95	V
SMALL SI	GNAL CHARACTERISTICS		-		•
f⊤	Current Gain - Bandwidth Product	Ic = 10 mA, Vce = 20 V, f = 100 MHz	300		MH:
Cobo	Output Capacitance	V <sub>CB</sub> = 5.0 V, I <sub>E</sub> = 0, f = 1.0 MHz		4.0	pF
Cibo	Input Capacitance	V <sub>EB</sub> = 0.5 V, I <sub>C</sub> = 0, f = 1.0 MHz		8.0	pF
	Noine Figure	In = 100 µA V = = 5.0 V		5.0	dB

2N3904

-

MMBT3904 / PZT3904

NPN General Purpose Amplifier

ta	Delay Time	$V_{cc} = 3.0 \vee, \vee_{BE} = 0.5 \vee,$	35	ns
tr	Rise Time	I <sub>c</sub> = 10 mA, I <sub>B1</sub> = 1.0 mA	35	ns
ts	Storage Time	V <sub>cc</sub> = 3.0 V, I <sub>c</sub> = 10mA	200	ns
t <sub>r</sub>	Fall Time	I <sub>B1</sub> = I <sub>B2</sub> = 1.0 mA	50	ns

 $^{*}$  Pulse Test: Pulse Width  $\leq$  300  $\mu$  5, Duty Cycle  $\leq$  2.0%

#### Spice Model

NPN (ls=6,734f Xit=3 Eg=1.11 Vaf=74.03 Bf=416.4 Ne=1.259 lse=6.734 lkf=66.78m Xtb=1.5 Br=.7371 Nc=2 lsc=0 lkr=0 Rc=1 Cjc=3.638p Mjc=.3085 Vjc=.75 Fc=.5 Cjc=4.493p Mjc=.2593 Vjc=.75 Tr=239.5n Tf=301.2p ltf=4 Xtf=4 Xtf=2 Rb=10)

Note: see page 12-15 of this document for more information on BJT SPICE parameters

© February 12, 2014 Dr. Lynn Fuller



### **BE AND BC DIODE CHARACTERISTICS**



Identify BE junction, measure ISE and VBE. Identify BC junction and measure IS. Identify Base, Emitter, Collector leads and label on sketch.

Rochester Institute of Technology

Microelectronic Engineering

### **BETA MEASURED FROM FAMILY OF CURVES**





### **BETA VS IC – 2N3904**



**Rochester Institute of Technology** 

Microelectronic Engineering

© February 12, 2014 Dr. Lynn Fuller



# 2N3904 SPICE MODEL

From the datasheet above

### Spice Model

NPN (Is=6.734f Xti=3 Eg=1.11 Vaf=74.03 Bf=416.4 Ne=1.259 Ise=6.734 Ikf=66.78m Xtb=1.5 Br=.7371 Nc=2 Isc=0 Ikr=0 Rc=1 Cjc=3.638p Mjc=.3085 Vjc=.75 Fc=.5 Cje=4.493p Mje=.2593 Vje=.75 Tr=239.5n Tf=301.2p Itf=.4 Vtf=4 Xtf=2 Rb=10)

h <sub>FE</sub>	DC Current Gain	$\begin{array}{l} I_{c} = 0.1 \text{ mA}, V_{cE} = 1.0 \text{ V} \\ I_{c} = 1.0 \text{ mA}, V_{cE} = 1.0 \text{ V} \\ I_{c} = 10 \text{ mA}, V_{cE} = 1.0 \text{ V} \\ I_{c} = 50 \text{ mA}, V_{cE} = 1.0 \text{ V} \\ I_{c} = 100 \text{ mA}, V_{cE} = 1.0 \text{ V} \end{array}$	40 70 100 60 30	300	
-----------------	-----------------	---	-----------------------------	-----	--

Why does the SPICE model have Bf of 416 when the maximum Bf=300

Answer: It is a model parameter and when combined with other model parameters give correct results. See next page.

Rochester Institute of Technology

Microelectronic Engineering

### **BJT SPICE PARAMETERS EFFECT ON BETA**

When BF=419 is used by itself it gives incorrect results

Adding IKF to the model helps reduce BF at high IC

Adding IS, ISE and NE makes the model give correct results for all IC

> Rochester Institute of Technology Microelectronic Engineering



QRITNPN NPN BF 416

QRITNPN NPN BF 416 IKF .06678

QRITNPN NPN BF 416 IKF .06678 IS 6.734000E-15 ISE 6.734000E-15 NE 1.259

© February 12, 2014 Dr. Lynn Fuller

**IC=VCD FAMILY OF CURVES** 



### 2N3904 FORWARD ACTIVE





### **TEMPERATURE EFFECT ON FAMILY OF CURVES**





### 2N3904 INVERSE MODE





### 2N3904 VBE STEPS



### **PNP FORWARD ACTIVE**





- 7. ICCAP Manual, Hewlet Packard
- 8. PSpice Users Guide.

Rochester Institute of Technology

Microelectronic Engineering

## LAB WORK USING HP4145

Obtain I-V plot for BE junction Obtain I-V plot for BC junction Obtain I-V plot for C-E Obtain Ic-Vce family of curves for 2n3904 (for different Ib's) Extract VA Early Voltage Extract Beta at 5 different IC values (0.1mA to 100mA) Obtain Ic-Vce family of curves at elevated temperature Obtain Ic-Vce family of curves for inverse operation Extract Beta Inverse Obtain Ic-Vce curves for different Vbe

Repeat some or all of above for 2N3906

**Rochester Institute of Technology** 

Microelectronic Engineering

HOMEWORK – BJT CHARACTERIZATION

Use SPICE to obtain the following:

- 1. Ic-Vce family of curves for 2N3904
- 2. Extract VA Early Voltage
- 3. Extract Beta at 5 different IC values (0.1mA to 100mA)
- 4. Obtain Ic-Vce family of curves at elevated temperature
- 5. Obtain Ic-Vce family of curves for inverse operation
- 6. Extract Beta Inverse
- 7. Obtain Ic-Vce curves for different Vbe



**Rochester Institute of Technology** 

Microelectronic Engineering